

## RESEARCH ARTICLE

### Thermal Properties and Glass Forming Capability of Hf-Al-Ni and Hf-Al-Cu Melt Spun Ribbon.

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#### ABSTRACT

The glass formability of melt spun Hf-Al-Ni and Hf-Al-Cu systems has been studied and found to be similar to comparable Zr-based systems. Results for XRD,  $T_g$ , and  $\Delta T_x$  are presented. A supercooled liquid region of 41K for  $Hf_{54}Al_{17.5}Ni_{28.5}$  and 52K for  $Hf_{45}Al_5Cu_{50}$  melt spun metallic glasses has been determined.

**Keywords:** Thermal Properties, Glass Forming Capability, Hf-Al-Ni and Hf-Al-Cu Melt Spun Ribbon

#### Introduction

The use of zirconium as a base element in alloys of good glass formability with the additions of other metallic elements are well established. Systems presented as good glass formers at cooling rates less than  $10^3K/s$  include Zr-Al-(Cu, Ni), Zr-Ti-Cu, Zr-Al-Ni-Cu, Zr-Ti-Be, and (Zr, Ti)-Al-Ni-Cu-(Pd, Be) [Johnson, 1994; Inoue, Shinohara, Yokoyama, & Masumoto, 1995]. Inoue et al (1995) has shown that ternary Zr-Al-(Cu, Ni) [Inoue, Kawase, Tsai, Zhang, Inoue & Masumoto, 1994] and quaternary Zr-Al-Ni-Cu [Shinohara, Yokoyama, Masumoto, Inoue & Zhang 1996] systems could produce bulk metallic glass (BMG) rods of diameter 30mm, while [A. Peker, W.L. Johnson] produced 40mm thick amorphous samples of alloys in the Zr-Ti-Ni-Cu-Be system having a supercooled liquid region- $\Delta T_x$  of up to 135K.

Chemically and physically, zirconium and hafnium are rather similar, having nearly identical atomic radii and the same number of oxidation states, therefore, one would expect that such glass-forming compositions would also form an amorphous phase if Hf was substituted for Zr.

There is limited published literature on Hf-based glass forming alloys. Earlier work examined melt spun Hf-(Ni, Co, Cu), Hf-Si-(Nb, V), and Hf-Co-Ni [Buschow 1984; Jansson & Nygren 1991]. Mechanical alloying has been used to form amorphous phases for Hf-(Ni, Cu, Ru) and  $Hf_{65}Al_{7.5}Cu_{17.5}Ni_{10}$  [Thompson, Politis, & Kim 1988; Damonte, Mendoza-Zélis & Eckert 2000]. [Zhang, Inoue & Masumoto 1994] found that  $Hf_{65}Al_{10}Ni_{25}$  and  $Hf_{65}Al_{10}Cu_{25}$  formed an amorphous phase with a  $\Delta T_x$  of approximately 30K and 50K respectively. Preliminary work on Hf-Ni-Cu [Zhang et al] showed that amorphous phases could be formed with Ni and Cu over a wide compositional range of up to 70at% (the balance being Hf), with  $Hf_{60}Ni_{20}Cu_{20}$  having a  $\Delta T_x$  of 65K. Recently Inoue et al [Inoue, Zhang & Kurosaka 2001] has reported a critical diameter for glass formation of 4mm for  $Cu_{60}Ti_{15}Hf_{25}$ . However, no systematic detailed results on glass forming characteristics have been published for Hf-Al-Ni or Hf-Al-Cu ternary systems.

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## Experimental

Using elements of purity >99.9wt% (Hf) or >99.99wt% (Al, Ni, Cu) 10g ingots were produced by arc melting, followed by casting of ribbon with thickness 25-35 $\mu$ m and width 3mm using single wheel melt spinning under an argon atmosphere at a surface wheel speed of 49m/s.

A digital transducer was used to determine sample thickness ( $\pm 1\mu$ m). A Philips XRD diffractometer with a CoK $\alpha$  source and a Dupont DSC unit were used for structural and thermal characterisation respectively. DSC analysis was carried out under argon atmosphere at 20 and 40K/min with an accuracy of  $\pm 10$ K per data point.

## Presentation and Discussion of Results

Figure 1 shows that an amorphous phase (within the XRD limits of detectable crystal size and volume percent) is formed over a wide compositional range for both Hf-Al-Ni and Hf-Al-Cu. Fully amorphous ribbon was formed between Hf 40 to 65at% for Hf-Al-Ni and from Hf 30 to 66at% for Hf-Al-Cu. In Hf-Al-Cu there are two regions of glass formation, possibly corresponding to eutectic or near eutectic compositions focused around Hf 35 to 45 at% and 50 to 66at% respectively. This is similar to the known regions of glass formation associated with Zr-based alloys, namely Cu<sub>60</sub>(Hf/Zr)<sub>40</sub> and Zr<sub>60</sub> (i.e. Zr<sub>55</sub>Al<sub>10</sub>Ni<sub>5</sub>Cu<sub>30</sub> to Zr<sub>65</sub>Al<sub>7.5</sub>Ni<sub>10</sub>Cu<sub>17.5</sub>). Hf-Al-Cu diffraction patterns indicate the presence of Hf<sub>2</sub>Cu in partly crystalline ribbons and of Al<sub>1.65</sub>Cu<sub>0.35</sub>Hf in Al rich crystalline samples. Only one range of glass formation is seen in Hf-Al-Ni, indicating that Ni is best used as an additive rather than as a main base element in Zr- or Hf-based bulk glass forming compositions.

These results are similar to results presented by Inoue et al [1990] for Zr-Al-Ni and Zr-Al-Cu [Inoue, Kawase, Tsai, Zhang & Masumoto 1994] melt spun ribbon. The range for which glass formation is detected for Zr-based alloys is greater than that for the respective Hf-based ternary alloy. This shows that Hf has a similar but diminished glass forming ability as Zr.

Figures 2 and 3 present values obtained for  $\Delta T_x$  ( $=T_x - T_g$ , where  $T_x$  and  $T_g$  are the temperatures of crystallisation and glass transition respectively) and  $T_g$  respectively.  $T_g$  is selected as the offset of the slope transition presented as I in Figure 4 (using this measure decreases the apparent magnitude of the supercooled liquid region). For Hf-Al-Ni,  $T_g$  ranges from 795K (Hf<sub>64</sub>Al<sub>8</sub>Ni<sub>28</sub>) to 893K (Hf<sub>50</sub>Al<sub>30</sub>Ni<sub>20</sub>), with  $\Delta T_x$  at a maximum of 41K for Hf<sub>54</sub>Al<sub>17.5</sub>Ni<sub>28.5</sub>. For Hf-Al-Cu,  $T_g$  varies from 801K (Hf<sub>66</sub>Al<sub>8</sub>Cu<sub>26</sub>) to 831K (Hf<sub>50</sub>Al<sub>20</sub>Cu<sub>30</sub>). In the two regions of glass formation for Hf-Al-Cu  $\Delta T_x$  is 48K for Hf<sub>60</sub>Al<sub>10</sub>Cu<sub>30</sub> and 52K for Hf<sub>45</sub>Al<sub>5</sub>Cu<sub>50</sub>.  $T_g$  for Zr-Al-Ni and Zr-Al-Cu is approximately 50K to 130K less than for the respective Hf-based alloys.

Figure 5 show results of Inoue et al [1990]; Inoue, Kawase, Tsai, Zhang & Masumoto 1994] for the respective Zr-based systems superimposed with results attained from this study for Hf-based systems (for the purpose of comparison here the onset of the glass transition is used as the measure of  $T_g$ , i.e. II in fig. 4). The regions of largest  $\Delta T_x$  for Hf-Al-(Ni, Cu) systems are similar to those of the comparable Zr-Al-(Ni, Cu) systems. The location of the largest  $\Delta T_x$  of  $\sim 70$ K and 69K for Zr-Al-Ni and Hf-Al-Ni respectively is Zr/Hf 55-65at% and Ni 20-30at%. For Zr-Al-Cu and Hf-Al-Cu the largest  $\Delta T_x$ 's are  $\sim 80$ K for both at Zr/Hf 60-70at% and Cu 25-35at% and  $\sim 60$ K and 100K at Zr/Hf 40-50at% and Cu 45-50at% respectively. Overall, the values of  $\Delta T_x$  and the compositions with a fully amorphous phase are smaller for the Hf-based systems. The only compositions of Hf based alloys to show an enhanced  $\Delta T_x$  are Hf 50-60at% Cu 45-55at% (although Hf 55-70at% still shows considerable potential for good glass formation).

No full explanation can be offered for the decrease in glass forming ability of Hf-Al-(Ni, Cu) compared with Zr-Al-(Ni, Cu). Several empirical and semi-empirical rules [Johnson. 1999; Davies & Luborsky, 1983; Inoue, Negishi, Kimura & Aoki 1997] which favour metallic glass formation can be considered:

1. multicomponent alloy systems consisting of more than three elements [Inoue, Zhang & Masumoto 1993],
2. significant difference of more than 13% in the atomic size ratios [Inoue et al 1993],
3. optimum negative heats of mixing among the constituent elements [Inoue et al 1993],
4.  $T_{rg}$ , ratio of  $T_g/T_l$ , ( $T_l$  being the liquidus temperature), with values greater than 0.6 [Davies 1976; Turnbull & Fisher 1949],
5. large supercooled region ( $\Delta T_x$ ); this is not a measure of, but rather a reflection of the glass forming ability of an alloy [Molokanov, Mikhailova, Kliger & Petrzhik 1997],

6. the absence of contaminants acting as sites for heterogeneous nucleation [Drehmann, Greer, & Turnbull 1982; Kui, Greer & Turnbull, 1984],
7. superheating a glass-forming alloy well above its melting temperature can contribute to the formation of an amorphous phase [Ling, Ochin, Marmelin, Faudot & Bigot 1996].

Concerning rule 1 and 2, there is no significant difference in atomic size ratios of the constituent elements between the Zr- and Hf-based ternary systems. In relation to rule 3, the heats of mixing between Zr-Al, Zr-Ni, Zr-Cu are -44, -49, -23 kJ/mol [Boer, Boom, Mattens, Miedema & Niessen 1988] respectively, while for Hf the respective heats of mixing between Hf-Al, Hf-Ni, Hf-Cu are -39, -42, -17 kJ/mol [Ling, Ochin, Marmelin, Faudot & Bigot. 1996], indicating that an amorphous phase containing Zr would be more stable and likely to resist crystallisation in thicker sections (and at lower cooling rates) than the comparable Hf-based composition with the same Al, Ni, and/or Cu quantities. *As for rule 4, work concerning  $T_{rg}$  and the effects of  $T_i$  and  $T_m$  (solidus temperature) is on-going and will be presented in a future publication.* Regarding rule 5  $\Delta T_x$  can be used as an intrinsic variable reflecting the glass formability, This limited use is due to; a) at different heating rates applied during thermal analysis,  $T_x$  (path dependent) will vary more than  $T_g$  (material property, dependent on solidification profile), thus distorting the measure of  $\Delta T_x$ , and (b); during solidification, the critical zone for vitrification will be the crystal-amorphous nose of the time-temperature transformation diagram and not  $T_g$  (where the viscosity will have reached a prohibitably high value, thus retarding rearrangement and crystallisation). Therefore,  $\Delta T_x$  values presented for Hf-based ternary alloys (fig. 5), when compared with those for Zr-based ternary indicate that Hf has some potential, but less than Zr, as a basis for glass forming alloys.

The melting temperatures of Zr and Hf are 2125K and 2500K respectively. Thus, with regards to rules 6 and 7; within the operating temperature limits of a particular casting unit, there would be a greater possibility for impurity phases in Hf-based alloys of surviving a melting process than for Zr-based alloys. This could lead to a larger number of active heterogeneous nucleation sites because of the reduced magnitude of superheat given to the system (due to the reduced superheat a particular unit can impose on a higher melting point Hf containing phase when compared to the similar lower melting point Zr phase).

## Conclusion

The glass formability of ternary Hf-Al-Ni and Hf-Al-Cu systems was presented. Results were compared with those previously published for Zr-Al-Ni and Zr-Al-Cu metallic glass forming systems.

Fully amorphous ribbon was formed for a content of Hf 40 to 65at%, Ni 10 to 35at% for Hf-Al-Ni and from Hf 30 to 66at%, Cu 20 to 60at% for Hf-Al-Cu. One centre for glass formation for Hf-Al-Ni was seen (fig. 1), approximately  $Hf_{60}Al_{20}Ni_{20}$  (same as Zr-Al-Ni) and two main centres for Hf-Al-Cu,  $Hf_{60}Al_{10}Cu_{30}$  and  $Hf_{45}Al_5Cu_{50}$  (similar to Zr-Al-Cu).  $\Delta T_x$  was seen to be at a maximum of 41K for  $Hf_{54}Al_{17.5}Ni_{28.5}$ , 48K for  $Hf_{60}Al_{10}Cu_{30}$  and 52K for  $Hf_{45}Al_5Cu_{50}$ . Possible explanations for the difference in glass formability between Zr- and Hf-based systems in terms of reduced negative heats of mixing, vulnerability to heterogeneous nucleation, and reduced superheating have been proposed. Work concerning the  $T_{rg}$  ratio of these systems is currently under way and will be published in due course.

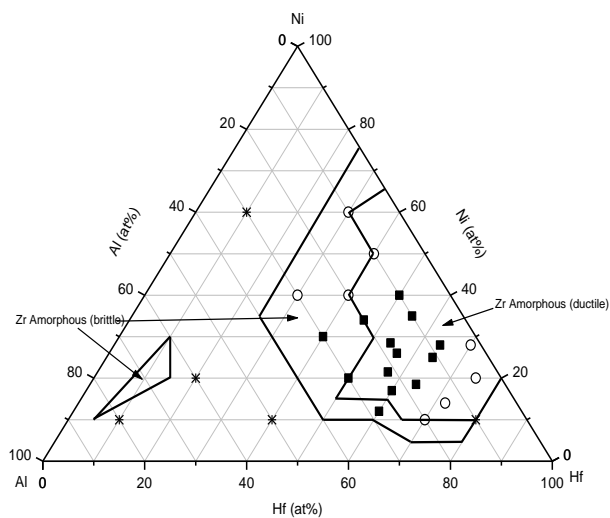
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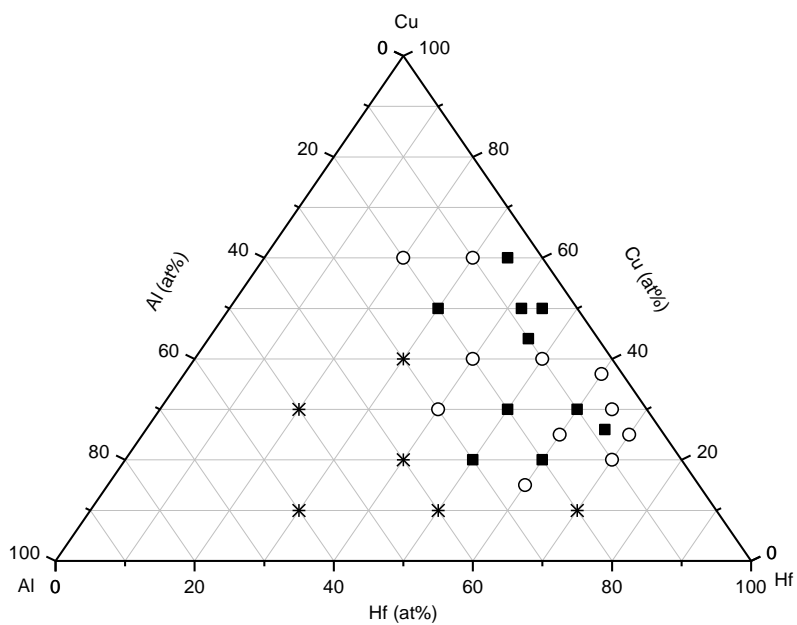
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APPENDIX I



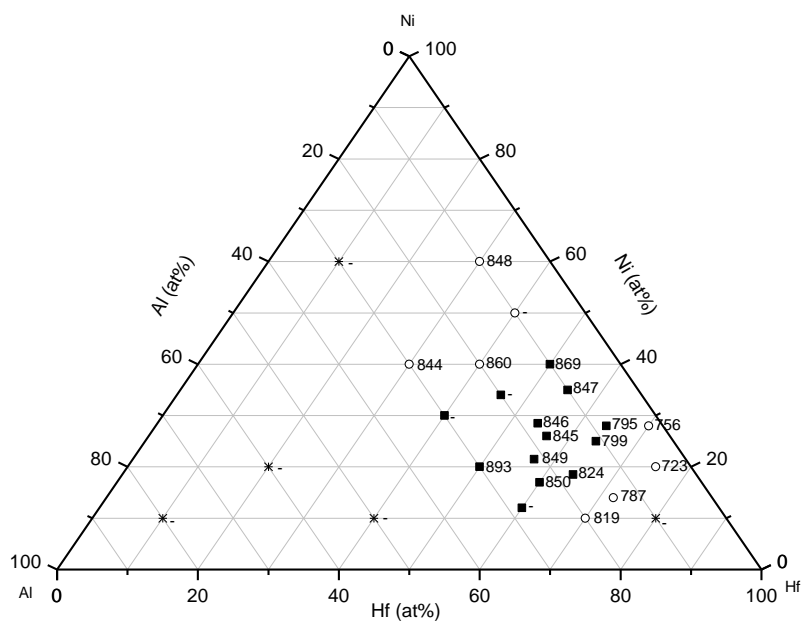
(a)



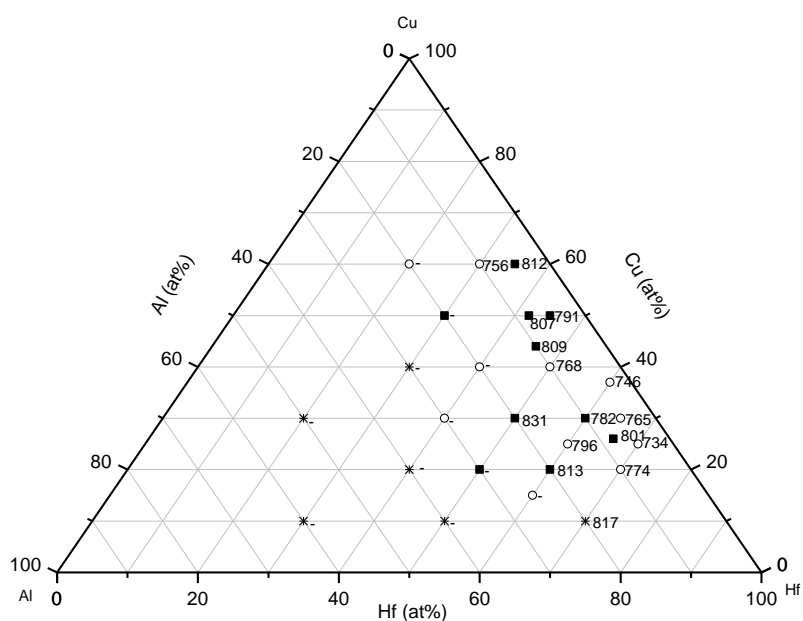
(b)

**Figure 1:** XRD results for melt spun ribbon; a) Hf-Al-Ni superimposed with results for Zr-Al-Ni (boundary line) [6], b) Hf-Al-Cu. Key: ■ = amorphous ○ = amorphous & crystalline, \* = crystalline.

APPENDIX II



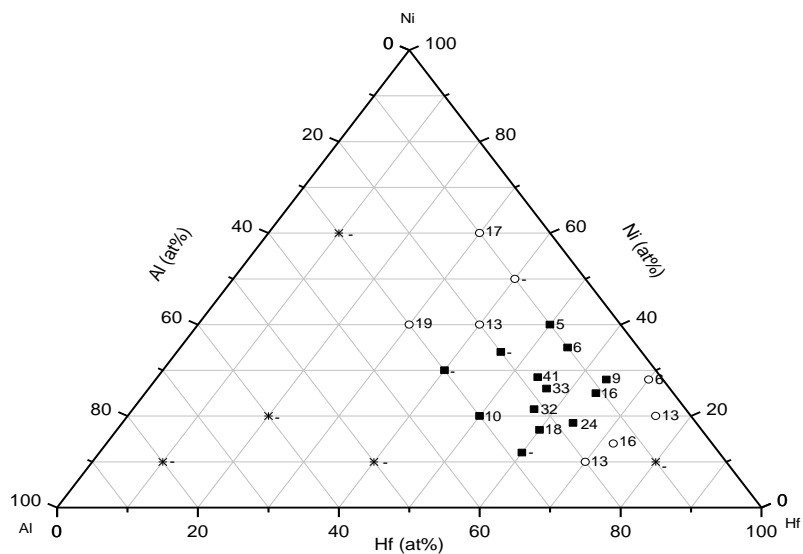
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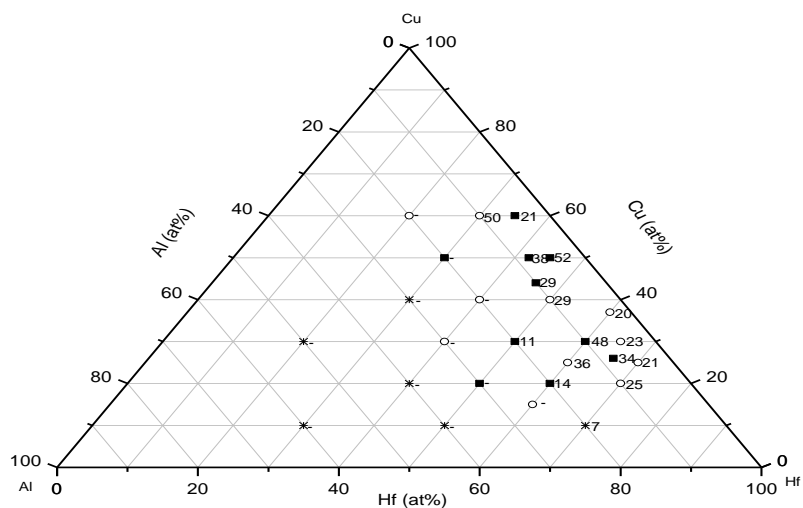
(b)

Figure 2: Values of T<sub>g</sub> attained by DSC at a heating rate of 20K/min for a) Hf-Al-Ni, and b) Hf-Al-Cu melt spun ribbon.

APPENDIX III



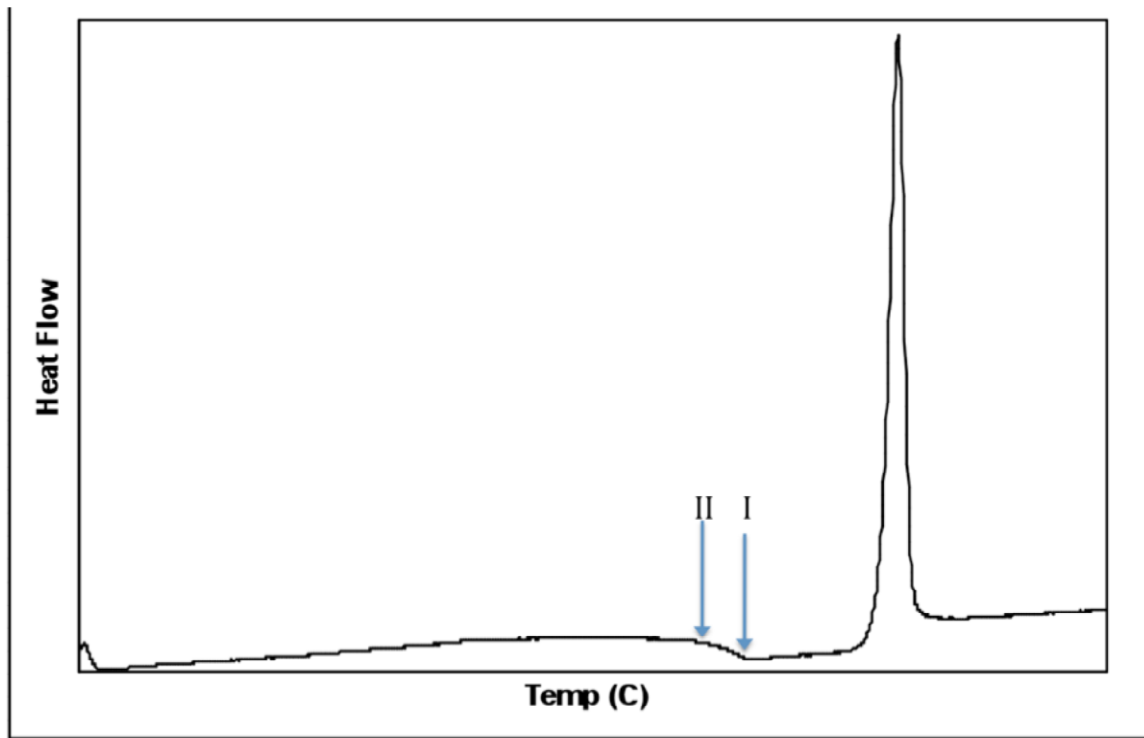
(a)



(b)

**Figure 3:** Values of  $\Delta T_x$  (supercooled liquid region,  $T_x - T_g$ ) at a heating rate of 20K/min for a) Hf-Al-Ni, b) Hf-Al-Cu melt spun ribbon.

APPENDIX IV



**Figure 4:** DSC plot of Hf-Al-Ni melt spun ribbon showing I, the offset of glass transition, giving  $T_g$  as chosen for Hf-based results presented, and II, the onset of glass transition, giving  $T_g$  as used in fig. 5 for comparison purposes.



